

Mark Name	Logo	Status	Country
300WORKS	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
A (stylized)	™ ®	Application Registered	China Australia Benelux Brazil Canada China European Union France Germany (Federal Republic of) Hong Kong India Indonesia Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Malaysia Mexico Philippines Russian Federation Singapore

A (stylized)	®	Registered	Spain Sweden Switzerland Taiwan Thailand United Arab Emirates United Kingdom United States of America
A (stylized) (with Cropped Banner Device)	®	Registered	China
A APPLIED MATERIALS (stylized in centered presentation)	®	Registered	China
A APPLIED MATERIALS (stylized)	®	Registered	China Thailand United States of America
A APPLIED MATERIALS MAKE POSSIBLE (stylized)	™	Application	China
ACCESS	®	Registered	Taiwan
	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
ACENTA	®	Registered	European Union International Japan Singapore Taiwan
	™	Allowed Application	United States of America China Korea, Republic of (KR)
ACTIVITY MANAGER	®	Registered	International

ACTIVITY MANAGER	®	Registered	Japan Korea, Republic of (KR) United States of America
Acuity	™	Application	China
	®	Registered	China European Union International Japan
	™	Allowed Application	United States of America Korea, Republic of (KR) Singapore Taiwan
ADEN	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
ADVENT	®	Registered	Taiwan
AdvisorMV	®	Registered	European Union United Kingdom
AERA	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore United States of America
AERIS	®	Registered	Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
	™	Application	European Union

AF-Mag

® Registered Benelux
 China
 Czechia
 Finland
 France
 Germany (Federal Republic of)
 Hungary
 India
 International
 Italy
 Japan
 Korea, Republic of (KR)
 Liechtenstein
 Poland
 Portugal
 Spain
 Sweden
 Switzerland
 Taiwan
 Turkey
 United Kingdom

AI Design Forum

® Registered United States of America

AI(X)

® Registered European Union
 International
 Israel
 Japan
 Singapore
 Taiwan

™ Allowed Application United States of America
 China
 Korea, Republic of (KR)

AIDF

® Registered United States of America

AITHION

® Registered Australia
 Canada

AITHION

® Registered China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United Kingdom

AIX

™ Allowed United States of America
® Registered European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan

AJAX

™ Allowed United States of America
Application China
® Registered China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

AKT

® Registered China
Germany (Federal Republic of)
Ireland (Republic of)
Japan
Korea, Republic of (KR)

AKT	®	Registered	Taiwan United Kingdom United States of America
	™	Application	China International
AKTIV	®	Registered	United States of America
	™	Application	China
Algorithms to Atoms	™	Allowed	United States of America
ALPS	®	Registered	United States of America
ALTA	®	Registered	France Germany (Federal Republic of) United States of America
ALTUM	®	Registered	Australia China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom
	™	Allowed Application	United States of America Canada
AMAT	®	Registered	Benelux
AMPLIPHI	®	Registered	China Taiwan
	™	Allowed Application	United States of America Japan Korea, Republic of (KR)
APF	®	Registered	United States of America
APF FUSION	®	Registered	United States of America

APF RTD	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APOLLO	®	Registered	Japan United States of America
	™	Allowed	Taiwan
		Published	Korea, Republic of (KR)
APPLIED	®	Registered	Benelux Japan
APPLIED AERIS	®	Registered	China
APPLIED AERIS-G	®	Registered	China
	™	Published	China
Applied AI(X)	™	Allowed	United States of America
APPLIED CHARGER	®	Registered	United States of America
APPLIED E3	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APPLIED ENDURA IMPULSE	®	Registered	Japan Korea, Republic of (KR) Taiwan
APPLIED FABVANTAGE	®	Registered	United States of America
Applied Forecast Parts Management	®	Registered	International

Applied Forecast Parts Management

® Registered Japan
Korea, Republic of (KR)
Taiwan
United States of America

APPLIED GLOBAL SERVICES

Applied Managed Service

® Registered United States of America
® Registered International
Japan
Taiwan
United States of America

APPLIED MATERIALS

® Registered Australia
Benelux
Brazil
Canada
China
European Union
France
Germany (Federal Republic of)
Hong Kong
India
Indonesia
International
Ireland (Republic of)
Israel
Italy
Japan
Korea, Republic of (KR)
Malaysia
Mexico
Philippines
Russian Federation
Singapore
Spain
Sweden
Switzerland

APPLIED MATERIALS	®	Registered	Taiwan United Arab Emirates United Kingdom United States of America
APPLIED MATERIALS A (stylized) (with Blue Banner Device)	™	Application	China
APPLIED MATERIALS A (stylized) and Chinese Characters	®	Registered	China
APPLIED MATERIALS A (stylized) and Chinese Characters (with Rounded Rectangle)	™	Published	China
APPLIED MATERIALS and Japanese Characters	®	Registered	China
APPLIED MATERIALS, INC	®	Registered	China
APPLIED MOSAIC	™	Application	United States of America
APPLIED OLYMPIA	®	Registered	Japan
APPLIED OLYMPIA ALD	®	Registered	Japan
Applied OnDemand	®	Registered	International Japan Taiwan United States of America
APPLIED OPUS	™	Application	China
APPLIED PERFORMANCE SERVICE	®	Registered	United States of America
APPLIED SANS A	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
APPLIED SMARTFACTORY	®	Registered	China European Union International Japan Singapore Taiwan United Kingdom United States of America
APPLIED SMARTFACTORY RX	®	Registered	China

APPLIED SMARTFACTORY RX	®	Registered	Taiwan
APPLIED THERMION	®	Registered	Japan Taiwan
APPLIED VENTURES	®	Registered	United States of America
AppliedAI(X) (stylized with superscript)	®	Registered	Canada European Union International Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom
appliedmaterials.tw	™	Allowed Application	United States of America Malaysia
AppliedPRO	®	Registered	Taiwan
AppliedTwin	®	Registered	Canada European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan
ARAGON	™	Allowed	United States of America
	™	Application	United States of America
	®	Registered	China International Japan Korea, Republic of (KR) Singapore

ARAGON	®	Registered	Taiwan
ArchitectMV	™	Allowed	United States of America
Arian	®	Registered	United Kingdom
ARISTO	™	Application	United States of America
ARNO	®	Registered	Germany (Federal Republic of)
	®	Registered	China
			International
			Japan
			Korea, Republic of (KR)
			Singapore
			Taiwan
AthenaAI	™	Allowed	United States of America
	®	Registered	European Union
			International
			Israel
			Japan
			Singapore
	™	Allowed	United States of America
		Application	Korea, Republic of (KR)
			Taiwan
Atoms to Algorithms	™	Allowed	United States of America
AUTOMOD	®	Registered	European Union
			International
			Japan
			Korea, Republic of (KR)
			Taiwan
			United Kingdom
			United States of America
AUTOSCHED	™	Published	China
	®	Registered	China
			European Union
			International
			Japan
			Korea, Republic of (KR)

AUTOSCHED	®	Registered	Singapore Taiwan United Kingdom United States of America
AVANTE	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan
AVATAR	™	Allowed	United States of America
	®	Registered	China
AVENIR	®	Registered	United States of America
AVILA	™	Allowed	United States of America
AVINA	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AXCELA	®	Registered	China European Union Singapore
	™	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
AXIOM	®	Published	United States of America
B (stylized)	®	Registered	United States of America
	®	Registered	Australia

B (stylized)

- ® Registered Belarus
- China
- Croatia
- European Union
- Hong Kong
- India
- International
- Italy
- Japan
- Korea, Republic of (KR)
- Norway
- Russian Federation
- Serbia
- Singapore
- Switzerland
- Taiwan
- Turkey
- Ukraine
- United Kingdom
- United States of America
- Vietnam

BACCINI (stylized)

- ® Registered Australia
- Belarus
- China
- Croatia
- European Union
- Hong Kong
- India
- International
- Italy
- Japan
- Korea, Republic of (KR)
- Norway
- Russian Federation

BACCINI (stylized)	®	Registered	Serbia Singapore Switzerland Taiwan Turkey Ukraine United Kingdom United States of America Vietnam
BatchMV	®	Registered	United Kingdom
BioAPC	®	Registered	Singapore United Kingdom
BioMV	™	Application	United States of America
BLACK DIAMOND	®	Registered	United Kingdom
BLACKHAWK	®	Registered	Japan United States of America China Korea, Republic of (KR) Taiwan
BLACKSTONE	™	Allowed	United States of America
	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
BLAZER	®	Registered	United States of America
Bridge	™	Application	United States of America
CARINA	®	Registered	United States of America
CATALYST	®	Registered	International
	™	Application	China European Union Japan Korea, Republic of (KR)

CATALYST	™	Application	Singapore Taiwan United States of America
CELLWORKS	®	Registered	Singapore United Kingdom United States of America
CENTINEL	®	Registered	United States of America
CENTRIS	®	Registered	China United States of America
CENTURA	®	Registered	Benelux China European Union France Germany (Federal Republic of) Hong Kong India Indonesia Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Singapore Spain Sweden Switzerland Taiwan United Kingdom United States of America
CENTURA (and Katakana version)	®	Registered	Japan
CENTURA WXP	®	Registered	Singapore Taiwan
ChamberAI	®	Registered	Canada European Union

ChamberAI	®	Registered	International Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United States of America
ChamberTwin	™	Application	China
Ciena	™	Application	Taiwan United States of America
CLARA	®	Registered	United States of America
CLARION	®	Registered	China International Korea, Republic of (KR)
CLARIPHI	®	Registered	China European Union International Korea, Republic of (KR) Singapore Taiwan United States of America
CLASS MCS 5	™	Allowed	Japan
	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan

CLASS MCS 5	®	Registered	United States of America
CLEAN MODE	™	Application	Malaysia
CLEANCOAT	®	Registered	United Kingdom
	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
CLERE	®	Registered	Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Taiwan
CloudSim	™	Allowed	United States of America
	®	Registered	European Union International
	™	Application	China Japan Korea, Republic of (KR) Singapore Taiwan
CLOVER	®	Published Registered	United States of America China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom

CLOVER	®	Registered	United States of America
CONFORMA	®	Registered	Taiwan
Contorno	™	Application	United States of America
Contour	™	Allowed	United States of America
ControlMV	®	Registered	United Kingdom
CORNERSTONE	®	Registered	United Kingdom
CORONA UV	®	Registered	Korea, Republic of (KR) Taiwan
CORSA	®	Registered	Australia Canada China European Union Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
CRION	™	Application	International
CrossMatch	®	Registered	United States of America
Cupryx	®	Registered	United States of America China European Union International
DARC	™	Allowed Application	United States of America Japan Korea, Republic of (KR) Singapore Taiwan
	®	Registered	Korea, Republic of (KR) Taiwan United States of America

DESICA	®	Registered	United States of America
DeviceTwin	™	Application	United States of America
Digital Dynamic Connection	™	Application	United States of America
DIMENSION	®	Registered	China France Germany (Federal Republic of) International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
DMO SYSTEMS	®	Registered	Taiwan
DPS	®	Registered	China European Union Korea, Republic of (KR) Singapore United Kingdom United States of America
DPS CENTURA	®	Registered	Benelux France Germany (Federal Republic of) Hong Kong Indonesia Ireland (Republic of) Italy Japan Korea, Republic of (KR) Singapore Spain Sweden United Kingdom

DPS CENTURA	®	Registered	United States of America
	™	Published	Taiwan
DRACO	®	Registered	International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
	™	Application	China
DROSSA	®	Registered	China International Japan Korea, Republic of (KR) Taiwan
	™	Allowed	United States of America
DSF	®	Registered	China European Union International Japan
	™	Allowed	United States of America
		Application	Korea, Republic of (KR) Singapore Taiwan
DURASOURCE	®	Registered	United States of America
DURUM	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
	™	Application	Malaysia
EcoTwin	®	Registered	European Union

EcoTwin	® ™	Registered Allowed Application	International United States of America China Japan Korea, Republic of (KR) Singapore Taiwan
ecoUP	™	Application	United States of America
EduTwin	™	Application	United States of America
Elevated Materials	™	Application	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ELi	™	Application	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
ELLUMINATOR	® ™	Registered Application	United States of America European Union International Japan United Kingdom United States of America China Korea, Republic of (KR) Taiwan
EMAX	®	Registered	United States of America

ENABLER	®	Registered	United States of America
ENDURA	®	Registered	Benelux China European Union France Germany (Federal Republic of) Hong Kong India Indonesia Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Singapore Spain Sweden Switzerland Taiwan United Kingdom United States of America
ENDURA CIRRUS	®	Registered	China European Union International United States of America
	™	Allowed Application	Japan Korea, Republic of (KR) Singapore Taiwan
ENDURA IMPULSE	®	Registered	China
	™	Allowed	United States of America
ENFLEXOR	®	Registered	United States of America
ENGINEERED OPTICS	®	Registered	International Japan

ENGINEERED OPTICS	® ™	Registered Application	Korea, Republic of (KR) European Union Japan Korea, Republic of (KR) Taiwan United States of America
ENGINEEREDWORKS	®	Registered	European Union Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
EngineeringTwin	™	Application	International
ENLIGHT	™	Application	United States of America
ENZO	®	Registered	United States of America
	®	Registered	China European Union International Japan Singapore Taiwan
	™	Allowed Application	United States of America Korea, Republic of (KR)
EPIC	™	Application	United States of America
Epic Center	™	Application	United States of America
ERGON	®	Registered	China International Japan Korea, Republic of (KR) Singapore Taiwan
ESATTO AOI	™ ®	Allowed Registered	United States of America China

ESATTO AOI	®	Registered	Taiwan
ESATTO HP kit	®	Registered	China
ESATTO HP+	®	Registered	Taiwan China Taiwan
ESATTO SEm	®	Registered	China Taiwan
ESATTO TECHNOLOGY	®	Registered	China Korea, Republic of (KR) United States of America
ESCOSYS	®	Registered	Austria Benelux China France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Spain Switzerland United Kingdom
ETERNA	®	Registered	China United States of America
ETERNA FCVD	™	Application	Korea, Republic of (KR) Taiwan
ETERNA TRINITY	®	Registered	Taiwan United States of America
EVEREST	™	Application	United States of America
EXECTA	®	Registered	China International Japan Korea, Republic of (KR)

EXECTA	®	Registered	Taiwan United States of America
EXPRESS EXCHANGE	®	Registered	United States of America
ExtractAI	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore
EYED	™	Application	United States of America
FAB300	®	Registered	United States of America
	®	Registered	Australia Benelux France Germany (Federal Republic of) Israel United States of America
FabOptimizer	®	Registered	United States of America
FACTORYWORKS	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
FCVD	®	Registered	China International Japan Korea, Republic of (KR) Malaysia Taiwan

FCVD	®	Registered	United States of America
FERMI	®	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
FINE LINE DOUBLE PRINTING	®	Registered	United States of America
FLDP	®	Registered	China Korea, Republic of (KR) Taiwan United States of America
FLDP (Chinese Characters)	®	Registered	China Taiwan
FLDP (in simplified Chinese characters)	®	Registered	China
FleetTwin	™	Application	United States of America
Forma	™	Application	United States of America
FormulateAPC	®	Registered	United Kingdom
FormulateMV	®	Registered	United Kingdom
Fortis	®	Registered	European Union International United States of America
	™	Allowed Application	China Japan Korea, Republic of (KR) Singapore Taiwan
FULLVISION	®	Registered	United States of America
GARNET	®	Registered	Korea, Republic of (KR)
	™	Allowed	United States of America
GEBI	®	Registered	Canada China European Union International Israel

GEBI	®	Registered	Japan Korea, Republic of (KR) Singapore Switzerland United Kingdom United States of America
GINESTRA	®	Registered	Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom United States of America
GUARDIAN	®	Registered	United States of America
HARP	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
HawkEye	®	Registered	European Union International Israel Japan Singapore Taiwan
	™	Allowed Application	United States of America Korea, Republic of (KR)

HEADSMART

® Registered China
European Union
International
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Taiwan
United Kingdom
United States of America

HIRES

® Registered China
Germany (Federal Republic of)
India
International
Italy
Japan
Korea, Republic of (KR)
United States of America

HydroClean

® Registered China
European Union
International
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom
United States of America

HydroCoat

® Registered European Union
International
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom

HyperSense

® Registered United States of America
International

HyperSense	™	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
IC^N	™	Application	United States of America
ICT	®	Registered	Germany (Federal Republic of)
ICT (and Design)	®	Registered	Germany (Federal Republic of) United Kingdom United States of America
IMAP	®	Registered	United States of America
IMPULSE	®	Registered	China European Union Korea, Republic of (KR) Taiwan United Kingdom
IMS	™	Application	United States of America
Indigo	®	Registered	European Union International
	™	Application	China Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Insepra	®	Registered	International
	™	Application	China European Union Japan Korea, Republic of (KR) Singapore

Insepra	™	Application	Taiwan United States of America
INSIGHT	™	Allowed	United States of America
InsightAI	®	Registered	European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
INSTAVISION	™ ®	Allowed Registered	United States of America China International Korea, Republic of (KR) Singapore Taiwan
INTEGRATED MATERIALS SOLUTION	®	Registered	United States of America International Japan United States of America
Intenza	™ ®	Application Registered	Korea, Republic of (KR) Singapore China European Union International Japan Singapore Taiwan
INVIA	™ ®	Allowed Registered	United States of America Korea, Republic of (KR) European Union Korea, Republic of (KR) Taiwan

INVIA	®	Registered	United Kingdom United States of America
	™	Application	China Japan
IONIQ	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
	™	Application	Singapore
IRIS	®	Registered	International
	™	Allowed Application	United States of America China European Union Japan Korea, Republic of (KR) Singapore Taiwan
ISANI	®	Registered	United States of America
ISCAN	®	Registered	United States of America
ISYSTEM	®	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
iSystem Foresight	®	Registered	European Union International Israel Japan

iSystem Foresight

® Registered Korea, Republic of (KR)
Singapore
™ Allowed United States of America
Application Canada
Malaysia
Switzerland

KEYSTONE

® Registered China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan

KINEX

® Registered United States of America
European Union
International
Japan
Taiwan
™ Allowed United States of America
Application China
Korea, Republic of (KR)
Singapore

KODIAK

® Registered International
Korea, Republic of (KR)
Taiwan

LAVACOAT

® Registered United States of America

LDS

™ Application United States of America

LEAD

® Registered Germany (Federal Republic of)
India
International
Japan
Korea, Republic of (KR)
Taiwan

Leopard	™	Application	United States of America
LIMITLESS EDGE	®	Registered	Benelux International Switzerland United Kingdom
	™	Allowed Application	United States of America India Singapore Sweden
LINK	®	Registered	United States of America
Lion	™	Application	United States of America
Lynx	™	Application	United States of America
MAKE POSSIBLE	®	Registered	European Union Japan Korea, Republic of (KR) Malaysia Singapore United Kingdom United States of America
MARANGONI	®	Registered	China Germany (Federal Republic of) Japan
MARATHON	®	Registered	Korea, Republic of (KR)
Materials to Systems	™	Allowed	United States of America
Materials to Systems Co-Optimization	®	Registered	European Union International Japan United Kingdom
	™	Allowed Application	United States of America Singapore Taiwan
MDLx	®	Registered	Canada China European Union

MDLx

® Registered International
Israel
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United Kingdom
United States of America

Mecatronix

™ Application

Japan

Mimansa

® Registered

Germany (Federal Republic of)

® Registered

International

™

Allowed

United States of America

Application

China

European Union

India

Japan

Korea, Republic of (KR)

Singapore

Mimansa AI

® Registered

International

™

Allowed

United States of America

Application

China

European Union

India

Japan

Korea, Republic of (KR)

Singapore

MIRRA

®

Registered

China

European Union

Hong Kong

India

Indonesia

Israel

Japan

MIRRA	®	Registered	Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
MIRRA (and Design)	®	Registered	European Union United Kingdom
MIRRA MESA	®	Registered	Korea, Republic of (KR) United States of America
ModuleTwin	™	Application	United States of America
Momentum Fund	™	Application	United States of America
monitorMV	®	Registered	United Kingdom
monitorMV (and Design)	®	Registered	United Kingdom
Morpher	™	Application	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
MSCO	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
MULTIWEB	™	Allowed	United States of America
	®	Registered	Benelux China France International

MULTIWEB	®	Registered	Italy Japan Switzerland United Kingdom
MUSTANG	®	Registered	United States of America
NANOCURE	®	Registered	International Korea, Republic of (KR) United States of America
NEMA	®	Registered	United States of America
NEOX	™	Allowed	United States of America
NEPTUNE	®	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
NetConnect	®	Registered	European Union International
	™	Allowed Application	United States of America China Israel Japan Korea, Republic of (KR) Singapore Taiwan
NEW ARISTO	®	Registered	China European Union Germany (Federal Republic of) Japan Korea, Republic of (KR) Taiwan United Kingdom

NEW ARISTO (in Chinese characters)	®	Registered	China
NEXUS-E	®	Registered	China European Union Germany (Federal Republic of) India Indonesia International Japan Korea, Republic of (KR) Mexico United Kingdom United States of America
NOKOTA	®	Registered	United States of America
NUCLEON	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan
NutriAPC	™	Allowed Application	United States of America China
NutriMV	®	Registered	United Kingdom
OLYMPIA	®	Registered	China International Singapore United Kingdom United States of America European Union International Taiwan United Kingdom
ONYX	®	Registered	United States of America
OPTA	®	Registered	China

OPTA	®	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
OPTIKON	®	Registered	United Kingdom
OPTIVA	®	Registered	United States of America
OPTOPLEX	®	Registered	Benelux China France Germany (Federal Republic of) International Italy Switzerland Taiwan United Kingdom
Palisade	®	Registered	European Union International Japan Singapore Taiwan United States of America
PALOMAR	™	Allowed Application	China Korea, Republic of (KR) United States of America
Panorama	™	Application	United States of America
PERCEPTIVE ENGINEERING	®	Registered	Singapore United Kingdom
Perceptive Engineering	®	Registered	United Kingdom
PerceptiveAPC	®	Registered	China International United Kingdom

PerceptiveAPC	™	Application	Singapore United States of America
PerformAPC	®	Registered	United Kingdom
PerformMV	®	Registered	United Kingdom
PHALCON	®	Registered	China European Union International Israel Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom
	™	Allowed Application	United States of America Canada Japan Korea, Republic of (KR)
PharmaAPC	®	Registered	United Kingdom
PharmaMV	®	Registered	China International Singapore United Kingdom United States of America
PharmaNeuron	®	Registered	United Kingdom
PIKA	®	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
PIONEER	®	Registered	China

PIONEER	®	Registered	European Union International Israel Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
	™	Application	Japan Malaysia
		Instructed	Japan
PISCES	™	Application	United Kingdom
PIVOT	®	Registered	China Germany (Federal Republic of) International Japan Korea, Republic of (KR) Taiwan
PiVot “樞紐” (Chinese translation of the meaning of PiVot)	®	Registered	Taiwan
PiVot ”樞紐” (Chinese translation of the meaning of PiVot)	®	Registered	China
Pixel Blending	™	Application	China European Union International Japan Korea, Republic of (KR) Singapore United States of America
POLARIS	®	Registered	European Union International Israel Korea, Republic of (KR) Singapore Taiwan

POLARIS	™	Allowed Application	United States of America Japan
Polestar	™	Application	United States of America
PPACT	®	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan
PPACT Enablement Company	™ ®	Allowed Registered	United States of America European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan
PRECISION	™ ®	Allowed Registered	United States of America China China International Japan Taiwan
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